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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/629,336	07/29/2003 Hong-Ki Kim 7590 05/23/2005	8836-195 (IB12091-US)	6317	
22150 7			EXAM	EXAMINER
F. CHAU & ASSOCIATES, LLC 130 WOODBURY ROAD			NGUYEN, TUAN H	
WOODBURY, NY 11797			ART UNIT	PAPER NUMBER
			2813	
			DATE MAILED: 05/23/2005	5

Please find below and/or attached an Office communication concerning this application or proceeding.

		· A	K
	Application No.	Applicant(s)	
	10/629,336	KIM ET AL.	
Office Action Summary	Examiner	Art Unit	
. ¥	Tuan H. Nguyen	2813	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet wit	h the correspondence address	
A SHORTENED STATUTORY PERIOD FOR RE THE MAILING DATE OF THIS COMMUNICATIO - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, a - If NO period for reply is specified above, the maximum statutory pe - Failure to reply within the set or extended period for reply will, by st Any reply received by the Office later than three months after the m earned patent term adjustment. See 37 CFR 1.704(b).	N. R 1.136(a). In no event, however, may a re reply within the statutory minimum of thirty riod will apply and will expire SIX (6) MONT atute, cause the application to become AB/	ply be timely filed (30) days will be considered timely. HS from the mailing date of this communication. NDONED (35 U.S.C. § 133).	
Status			
 1) ⊠ Responsive to communication(s) filed on 1/2 2a) ⊠ This action is FINAL. 2b) ☐ 3 3) ☐ Since this application is in condition for all closed in accordance with the practice und 	This action is non-final. wance except for formal matte		:
Disposition of Claims		•	
4) ⊠ Claim(s) 1-4,23,25 and 26 is/are pending in 4a) Of the above claim(s) is/are with 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-4,23,25 and 26 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction are	drawn from consideration.		
Application Papers			
9) ☐ The specification is objected to by the Exar		=	
· · · · · · · · · · · · · · · · · · ·	accepted or b) objected to I		
Applicant may not request that any objection to Replacement drawing sheet(s) including the co			
11) The oath or declaration is objected to by the			
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for form a) All b) Some * c) None of: 1. Certified copies of the priority docum 2. Certified copies of the priority docum 3. Copies of the certified copies of the application from the International But * See the attached detailed Office action for a	nents have been received. nents have been received in A priority documents have been ireau (PCT Rule 17.2(a)).	pplication No received in this National Stage	
Attachment(s)	A) 🔲 Interview C	ummary (PTO-413)	
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948 Information Disclosure Statement(s) (PTO-1449 or PTO/SI Paper No(s)/Mail Date 	Paper No(s)/Mail Date formal Patent Application (PTO-152)	

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-4, 23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Cho (cited ref.).

Cho, figs. 4-8 and text on col. 4-7 discloses substantially the claimed capacitor including a lower electrode 24 formed on a semiconductor substrate 20; a dielectric film 25 stacked on the lower electrode 24; and a first TiN upper electrode 26 formed by CVD and a second TiN upper electrode formed by PVD (fig. 6, col. 5, last two paragraphs).

Cho does not particularly show the concave-type capacitor as now claimed; however, on col. 5, lines 40-42, Cho clearly suggests that the invention could be applied to form capacitor with various shapes including to either box shape (convex-type), or crown, cylinder (concave-type).

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have formed upper capacitor electrode by CVD and PVD for either convex type or concave-type capacitor as suggested by Cho since the substitution of art recognized equivalence as suggested, is within the level of those skilled in the art.

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With respect to claim 4, col. 6, first paragraph discloses another TiN layer subsequently formed by CVD as the upper electrode which is considered as a second upper electrode.

Claims 25-26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Cho as applied to claims 1-4, 23 above, and further in view of Roberts et al..

Cho, figs. 4-8 and text on col. 4-7 discloses substantially the claimed capacitor as explained above, except the formation of anti-reflective layer on the second upper electrode.

Roberts et al., in a related capacitor structure, as shown in fig. 11, teaches the use of anti-reflective layer 75 over the second upper electrode. Note on col. 5, lines 15-23 for the formation of upper electrode by either PVD, CVD, ALD or the combination thereof for forming electrode 60 of any conductive material such as tantalum, tantalum nitride, titanium, titanium nitride, ruthenium... or their combination.

It would have been obvious to one having ordinary skill in the art at the time the invention was made to have formed the antireflective layer over the upper capacitor electrode as suggested by Roberts et al. in the concave-type capacitor structure from Cho for serving as an etch stop and improving optical properties during subsequent photolithography process (col. 5, lines 35-46).

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP

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§ 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Response to Arguments

Applicant's arguments with respect to claims 1-4, 23 have been considered but are moot in view of the new ground(s) of rejection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tuan H. Nguyen whose telephone number is 571-272-1694. The examiner can normally be reached on 9AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl Whitehead Jr. can be reached on 571-272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Tuan H. Nguyen
Primary Examiner
Art Unit 2813